

# Poster Presentations

## [MS31-P03] Alternative criteria for optimal data collection strategy

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Approaches to determining the influence of individual measurements on the precision of crystallographic least squares parameters have been known for a long while [1,2,3,4,5]. Situations in which the precision of a single parameter (or linear combination of parameters) is critical can include: determination of novel bond lengths; refinement of site occupancies in mixed metal or mixed oxidation state systems; determination of the fraction of excited state molecules in a time-resolved pump-probe experiment. Such calculations are easily applicable to point-detector instruments, where individual influential reflections could be remeasured one-by-one. However, on a modern area detector instrument many reflections are measured on one frame and therefore some consideration of the appropriate strategy of reciprocal space scans is permitted to allow a more efficient use of the instrument. We present an analysis of diffractometer strategy selection to prioritize scans which give the best improvement in specific least-squares parameters.

[1] Prince, E. (2004). *Mathematical Techniques in Crystallography and Materials Science*, 2nd ed. Berlin: Springer.

[2] David, W. I. F., Ibberson, R. M. & Matsuo, T. (1993). *The Proceedings of the Royal Society of London A* **442**, 129-146.

[3] Prince, E. & Spiegelman, C. H. (2004). *International Tables for Crystallography, Vol. C*, pp. 702-706, edited by E. Prince. Dordrecht: Kluwer Academic Publishers.

[4] Prince, E. & Spiegelman, C. H. (2004). *International Tables for Crystallography, Vol. C*, pp. 707-709, edited by E. Prince. Dordrecht: Kluwer Academic Publishers.

[5] Rawlings, J. O., Pantula, S. G. & Dickey, D. A. (1998). *Applied Regression Analysis: A Research Tool*, 2nd ed. New York: Springer.

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